

# Abstracts

## Millimeter Resonance Isolator Using Chemically Deposited Ferrite Films (Correspondence)

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*W. Wade, Jr., T. Collins and R. Stern. "Millimeter Resonance Isolator Using Chemically Deposited Ferrite Films (Correspondence)." 1962 Transactions on Microwave Theory and Techniques 10.6 (Nov. 1962 [T-MTT]): 611-611.*

An experimental resonance isolator showing the feasibility of newly developed chemically deposited ferrite films, was made in the 35-Gc region. Included in this letter are two graphs showing the isolation characteristics that were obtained and also a brief description of the film preparation techniques.

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